

Notice of References Cited	Application/Control No. 09/916,064	Applicant(s)/Patent Under Reexamination SEIGLER ET AL.	
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U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,483,662	11-2002	Thomas et al.	360/126
	B	US-6,455,177	09-2002	Everitt et al.	428/693
	C	US-6,445,536	09-2002	Rudy et al.	360/126
	D	US-5,841,692	11-1998	Gallagher et al.	365/173
	E	US-6,043,959	03-2000	Crue et al.	360/317
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	JP 09092906 A	04-1997	Japan	YAOI, TOSHIHIKO	H01L 43/08
	O	JP 07326024 A	12-1995	Japan	SMITH, NEIL	G11B 05/39
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	"Effect of microstructure on resistivity and GMR ratio in ion beam deposited spin valves"; Bailey, W.E.; Guarisco, D.; Wang, S.X.; Magnetics, IEEE Transactions on , Volume: 34 Issue: 4; July 1998; Page(s): 957 -959.
	V	"Giant magnetoresistance of current-perpendicular exchange-biased spin-valves of Co/Cu"; Reilly, A.C.; Chiang, W.-C.; Park, W.; Hsu, S.Y.; Loloee, R.; Magnetics, IEEE Transactions on , Volume: 34 Issue: 4 , July 1998; Page(s): 939 -941.
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.

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